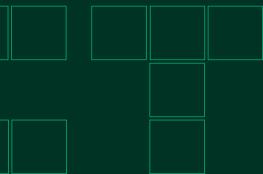


Advanced Battery Cell Testing Techniques







Felipe Quintana Principal Systems Engineer

Presenter: Felipe Quintana

Over 10 years of experience developing automated test systems for validation and manufacturing of EV powertrain, with a focus on battery.

As a Principal Systems Engineer at NI Transportation, I am responsible for the design and deployment of industry-driven hardware and software test solutions. Previously, I worked as a manufacturing Engineer for Tesla.





Agenda

- Presenter Introduction
- Cell Testing Challenges and Impact
- Common Cell Quality Testing Techniques
- Common Cell Defects
- Technical Background
- DCIR
- ACIR
- EIS
- The NI Advantage



Cell Testing Challenges and Impact

Challenges Impact Time and Data Performance Standardization Safety Ē Limited Techniques Longevity

•



Common Cell Quality Testing Techniques

Use-Cases and Considerations

Test	DUT	Description
OCV	Cell, Module or Pack	Performed periodically throughout aging process to evaluate leaka Can also be used to ensure balance, though that is increasingly th
ACIR	Cell	More comprehensive evaluation of cell quality and formation proce 1kHz
EIS (<1kHz)	Cell	Measures the impedance of a cell across a spectrum of different fr response with a data model to screen for specific failure modes an
High-Frequency EIS (>1kHz)	Cell	Measures the impedance of a cell across a spectrum of different fr response with a data model to screen for specific failure modes an Higher frequencies are useful for specific defects and reduce over
High Pressure Current Detection (HPCD)	Pouch Cell	Leakage testing of pouch cells while applying mechanical pressure The physical force is intended to aggravate micro-shorts
Standard Leakage Testing	Cell or Module	Precisely determines the cell voltage before putting the SMU into a while measuring the required current
DCIR	Cell, Module or Pack	Application of a current pulse, generally high current, to analyze th battery reacting to DC pulses



kage testing over time. the responsibility of the pack

cess that injects current at

frequencies and compares and bin them appropriately

frequencies and compares and bin them appropriately. erall test time

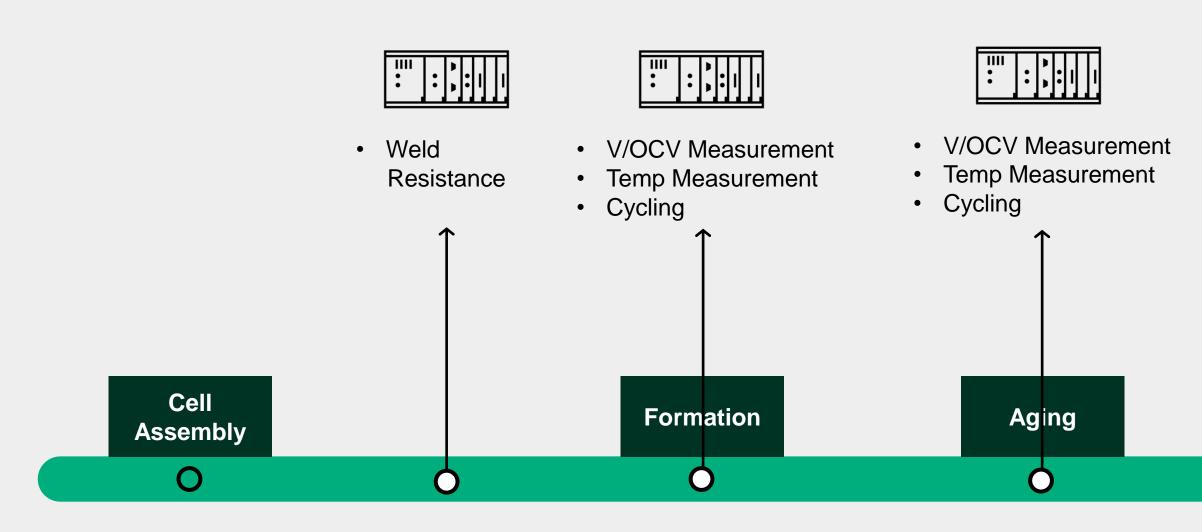
re to the structure of the cell.

a steady state voltage mode

the internal resistance of the

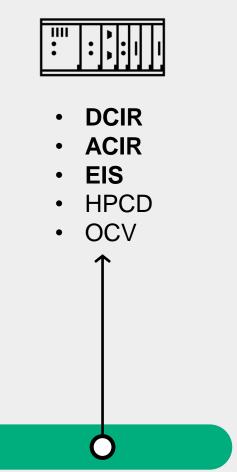


NI Battery Cell Production Test Solutions



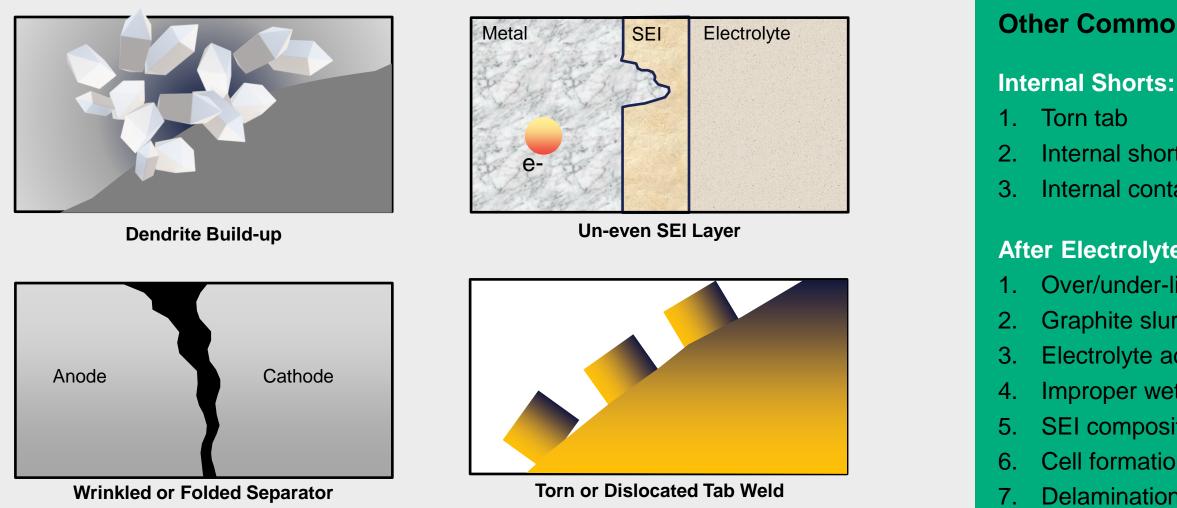
Test Station with NI/Cell Quality Offering Content \mathbf{O}







Advanced Measurement Solutions are Required to Catch All Failure Modes



Basic OCV/Resistance measurements are not enough to detect all failure modes

Other Common Defects Include:

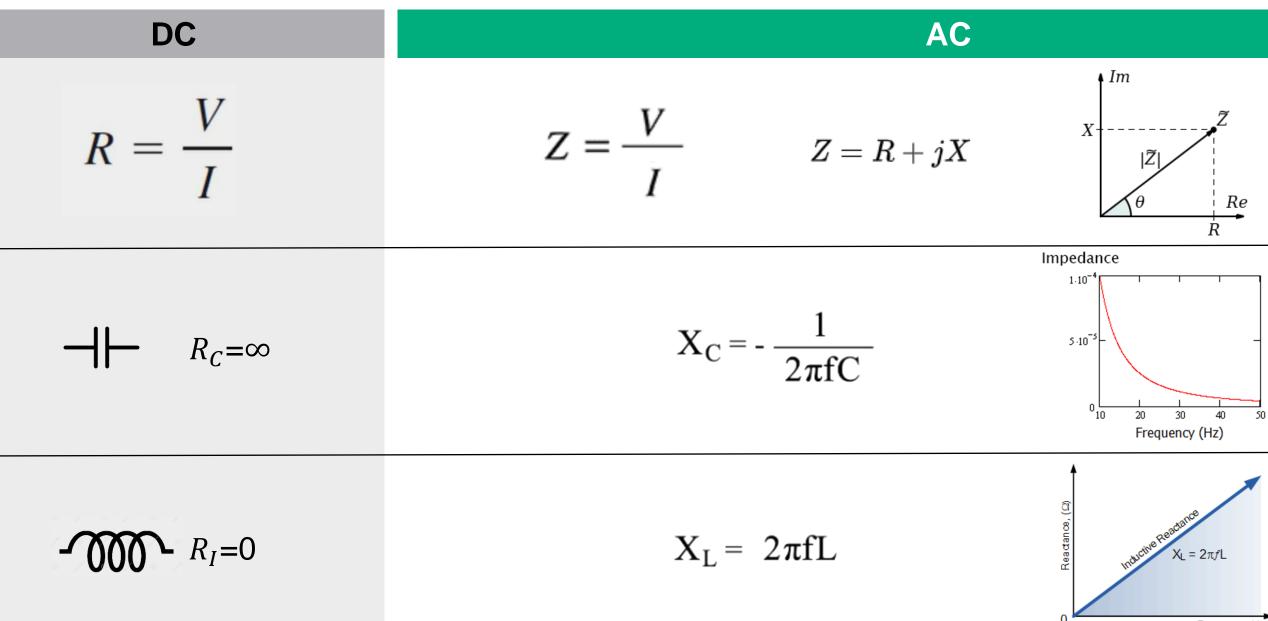
- Internal shorting
- Internal contamination

After Electrolyte is Added:

- Over/under-lithiation
- Graphite slurry defect
- Electrolyte additive mixture defect
- Improper wetting
- SEI composition and distribution Cell formation recipe assessment Delamination



Technical Background | Impedance



Frequency, Hz

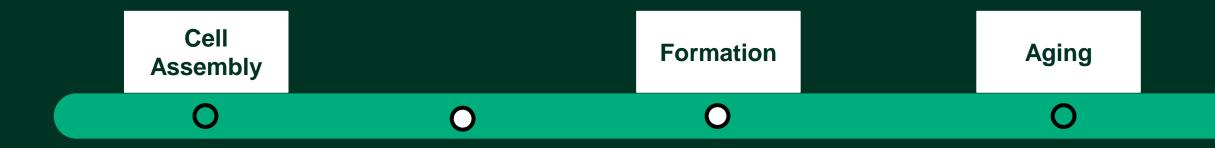


Technical Background | Cell Model





DC Internal Resistance (DC-IR)



O Test Station with NI/Cell Quality Offering Content



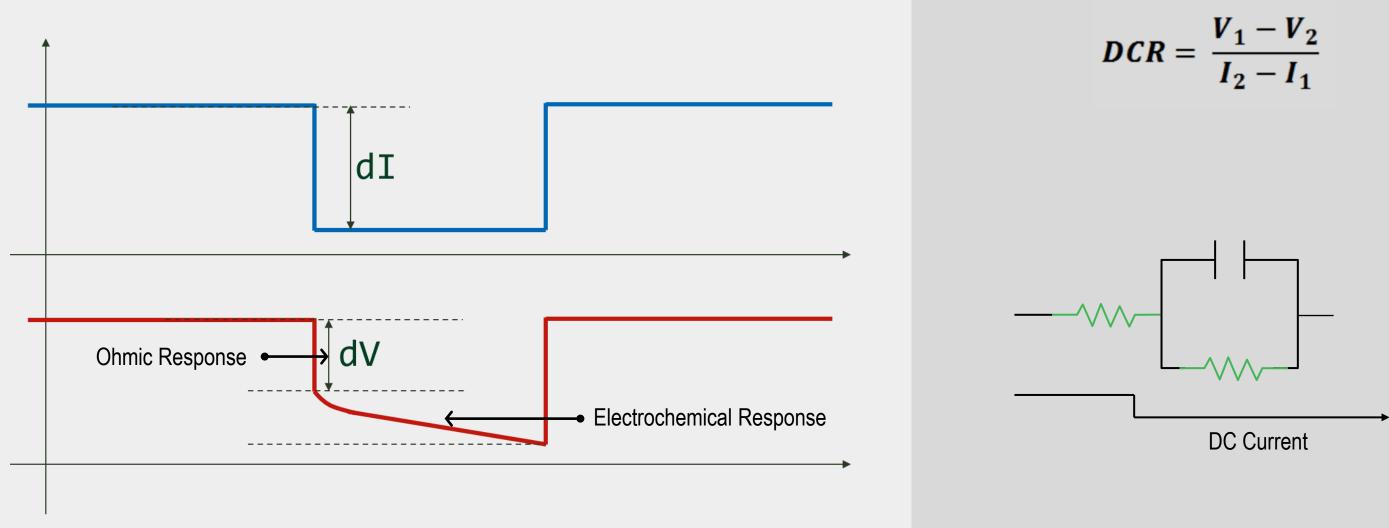
• DCIR

- ACIREIS
- HPCD
- OCV

 \bigcirc



Test Process | **DC Internal Resistance (DC-IR)**

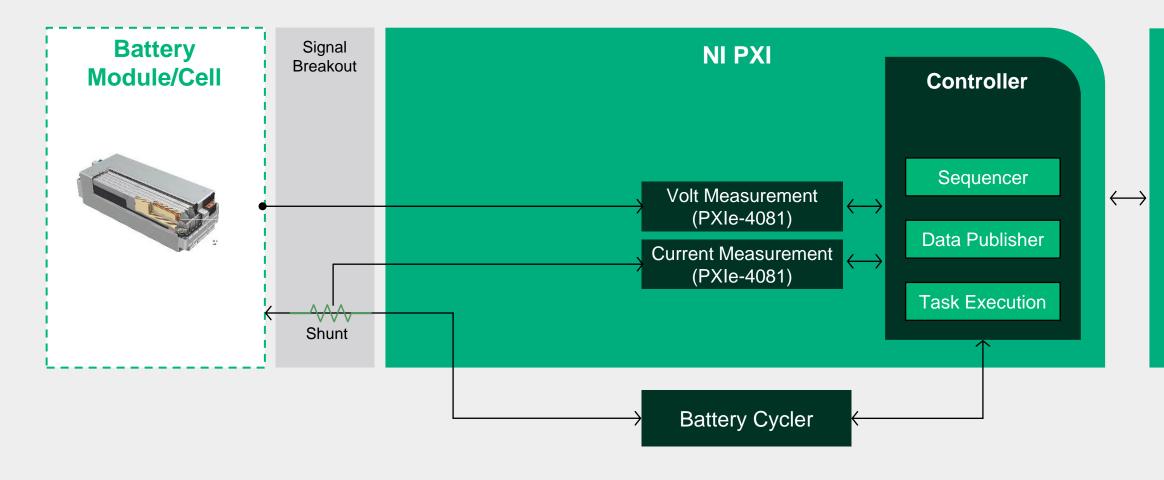


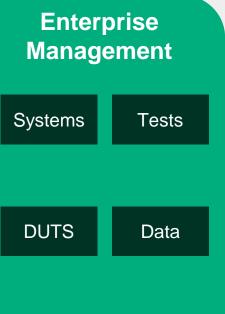




The NI Solution

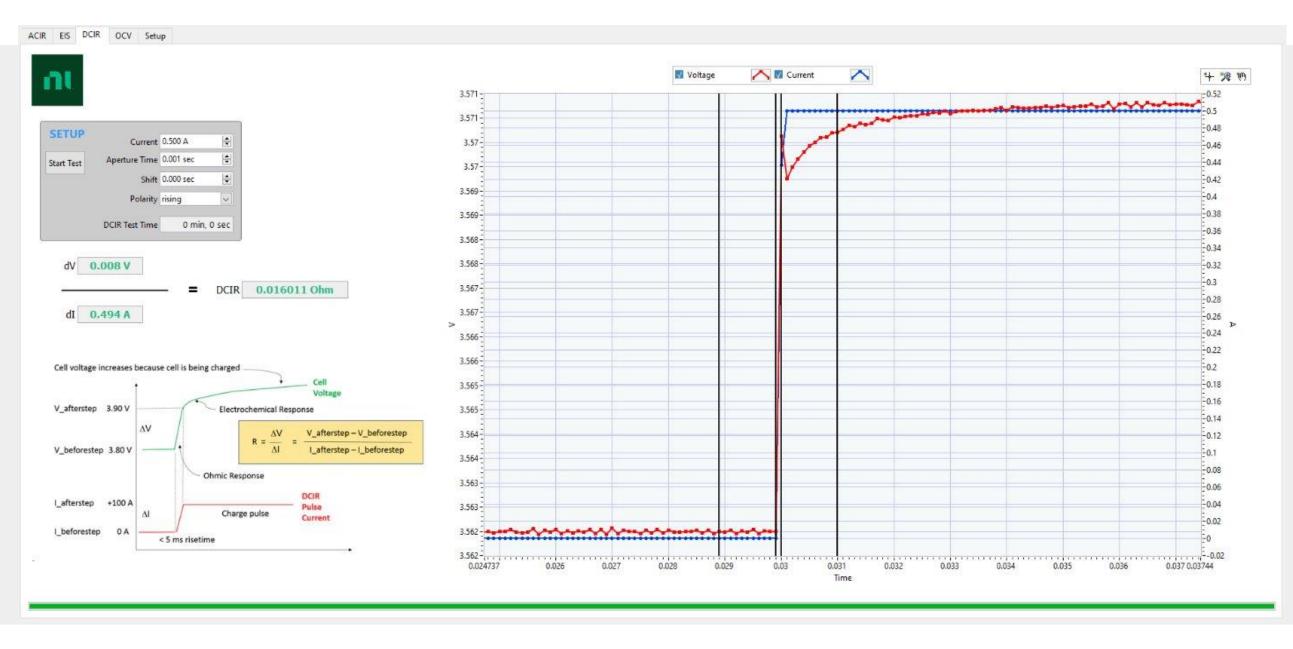
DC INTERNAL RESISTANCE (DC-IR)







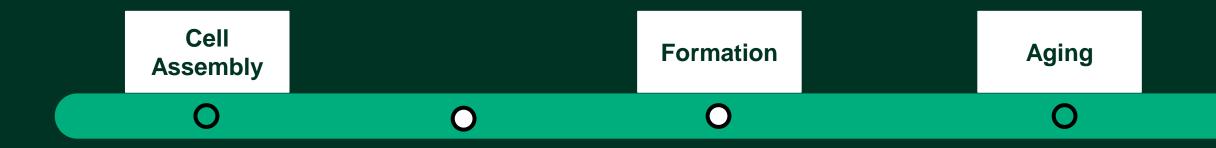
NI Cell Quality Software DC-IR Example







AC Internal Resistance (AC-IR)



O Test Station with NI/Cell Quality Offering Content



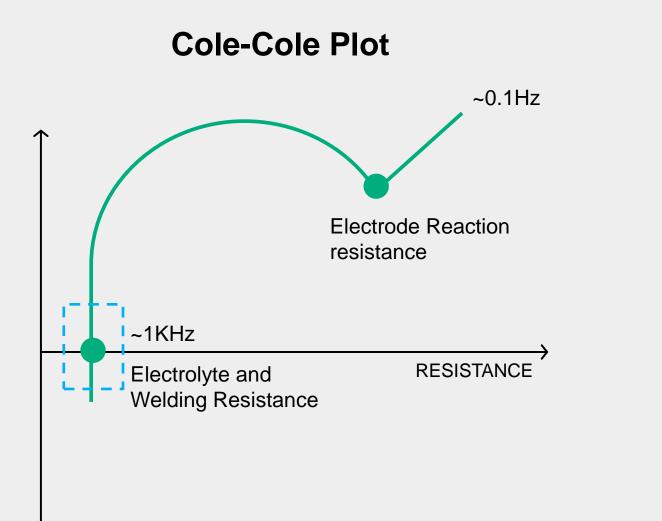
DCIRACIR

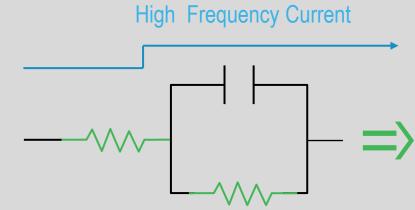
- EIS
- HPCD
- OCV

 \bigcirc



Test Process AC Internal Impedance (AC-IR)



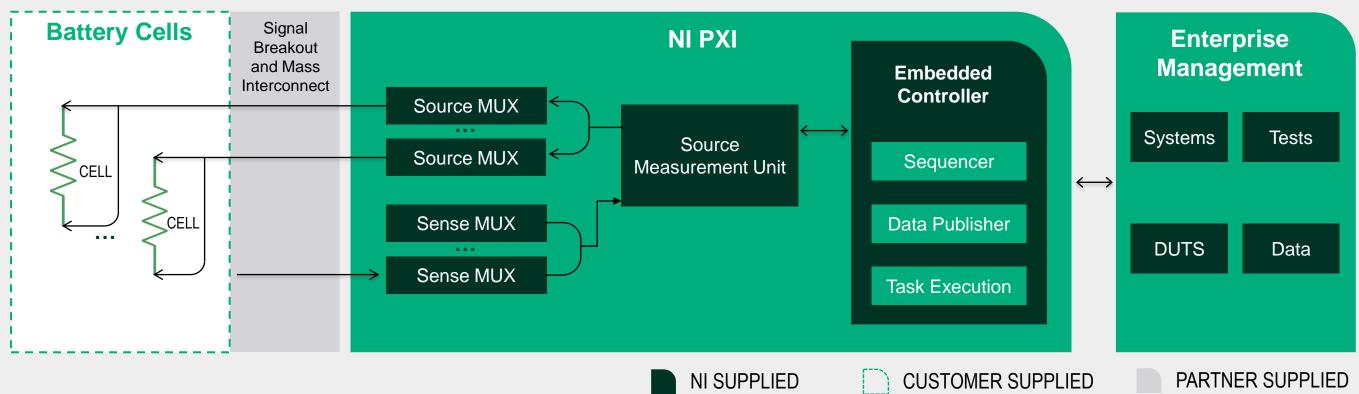






The NI Solution

AC INTERNAL RESISTANCE (AC-IR)



SPECIFICATIONS

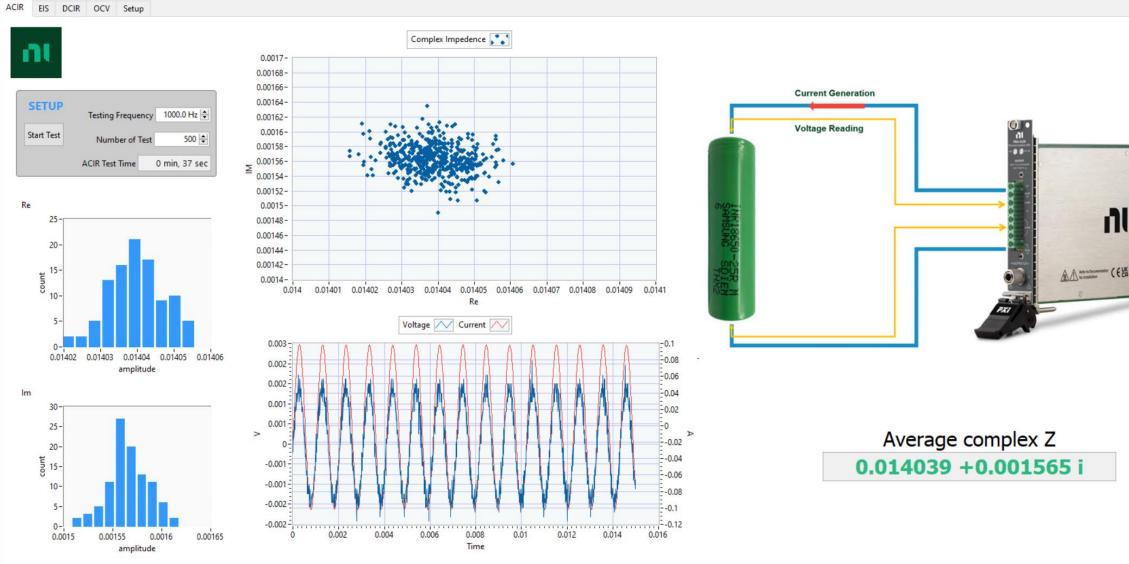
- Current
- Frequency
- Repeatability
- Cycle Time
- Channels

100mA - 2A
1kHz
1μΩ
10 cells/second
Up to 480 in 3U chassis*

*CAN BE SCALED BASED ON APPLICATION REQUIREMENTS



NI Cell Quality Software AC-IR Example

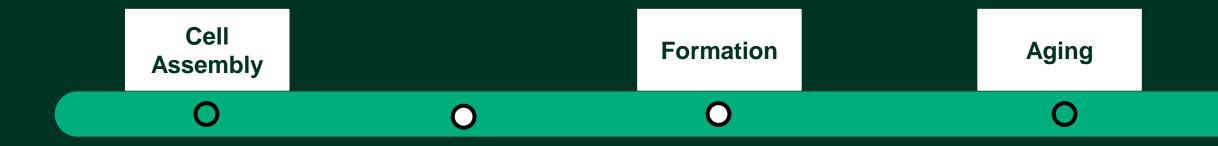




1	
H6&I0	
0	



Electrochemical Impedance Spectroscopy (EIS)



Test Station with NI/Cell Quality Offering Content

 \mathbf{O}





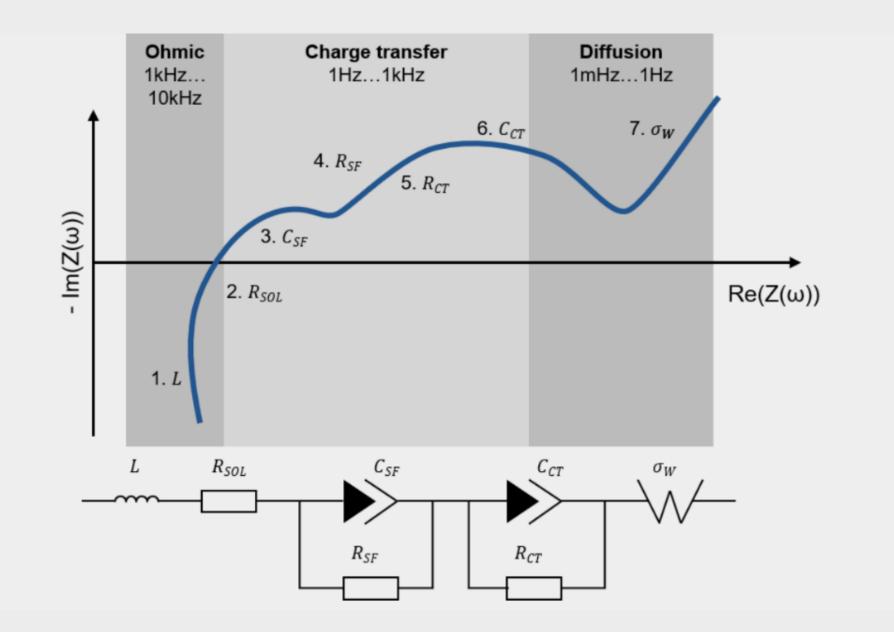


- HPCD
- OCV

 \bigcirc

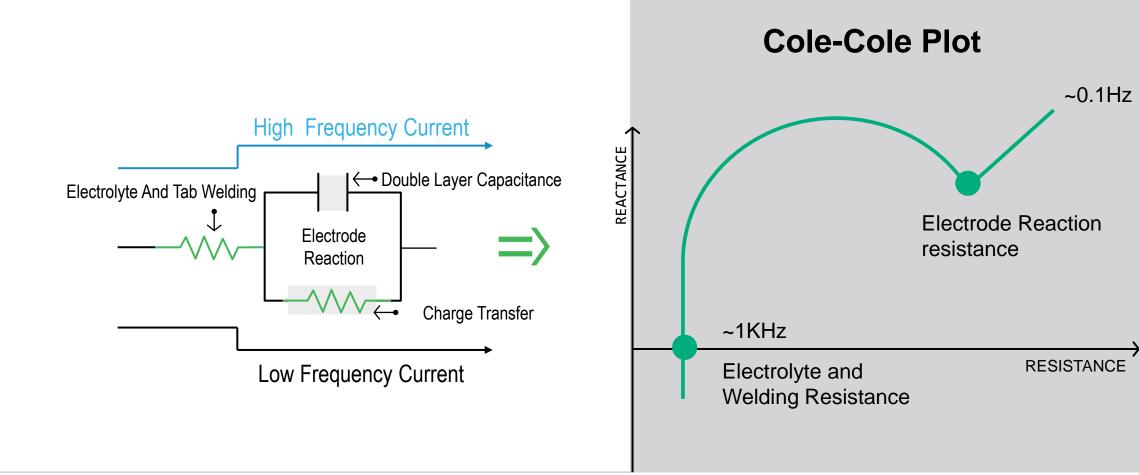


Test Data Map to Cell Model





Test Process | **EIS**





The NI Solution

SPECIFICATIONS

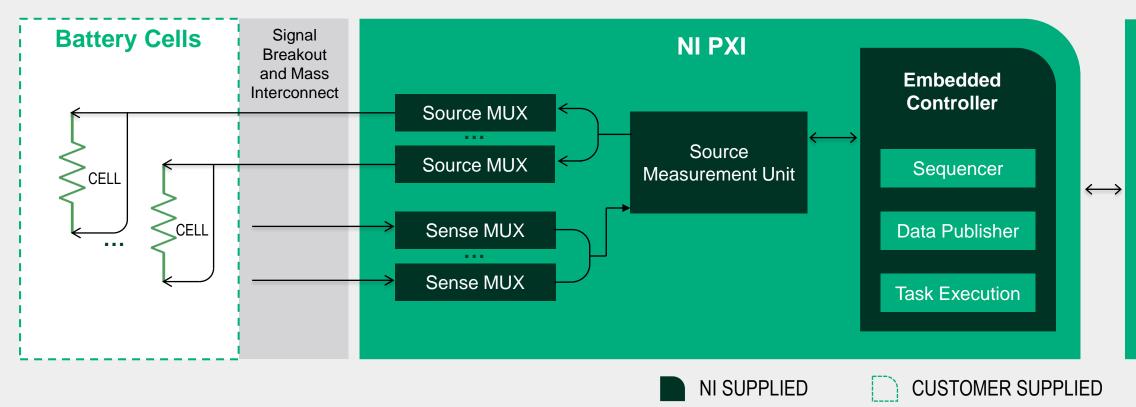
Current

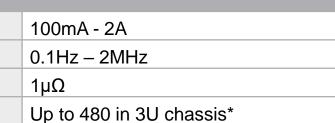
Frequency

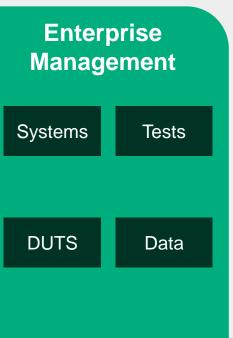
Repeatability

Channels

ELECTROCHEMICAL IMPEDANCE SPECTROSCOPY (EIS)





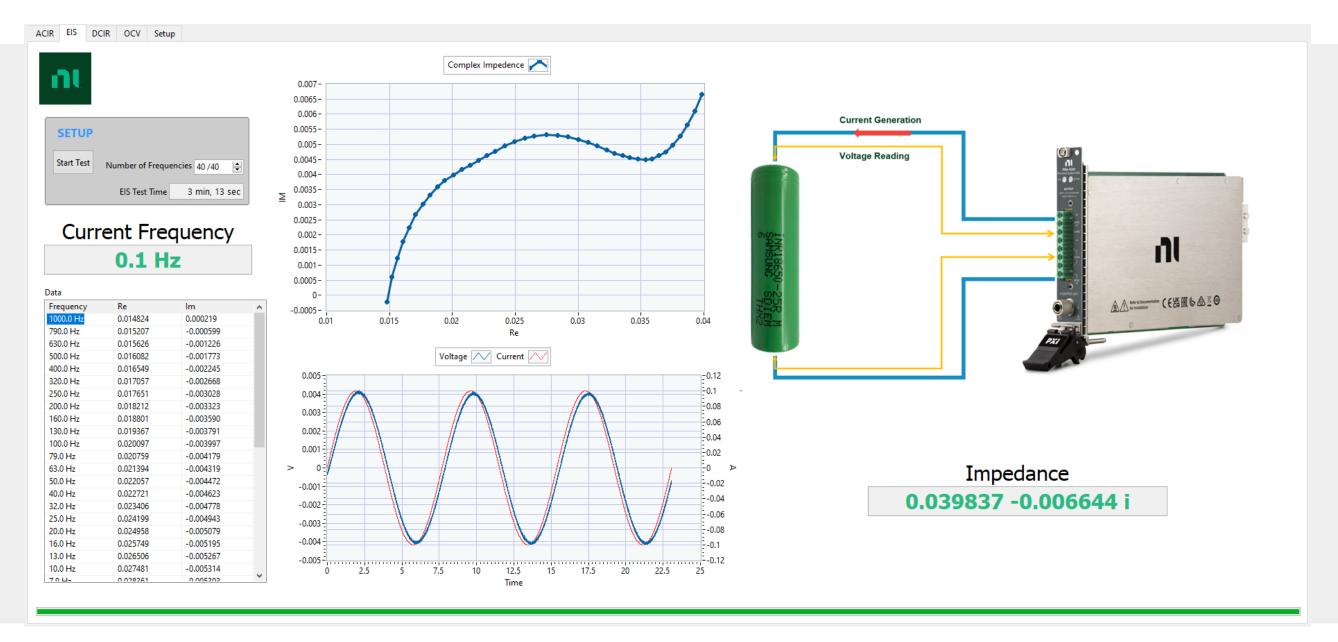


PARTNER SUPPLIED

*CAN BE SCALED BASED ON APPLICATION REQUIREMENTS



NI Cell Quality Software EIS Example





Why NI



PXI Solution for Cell Quality and Inspection

Flexibility

Modular, Programmable Hardware

Future-proof systems with reconfigurable hardware that can support various measurements and test techniques

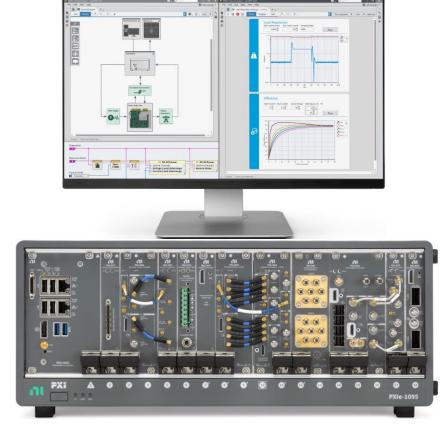
Measurement IP

Out-of-the-box Solution

Pre-built IP for advanced battery test techniques, including OCV, ACIR, EIS, HPCD and others

Production Ready Rugged and Reduced Footprint

Integrate multiple instruments and channel expansion into a single chassis



Software **Systems and Data Management**

Integrates with solutions for managing system configuration, remote monitoring, and data aggregation and analysis

Measurement Quality Accuracy and Repeatability

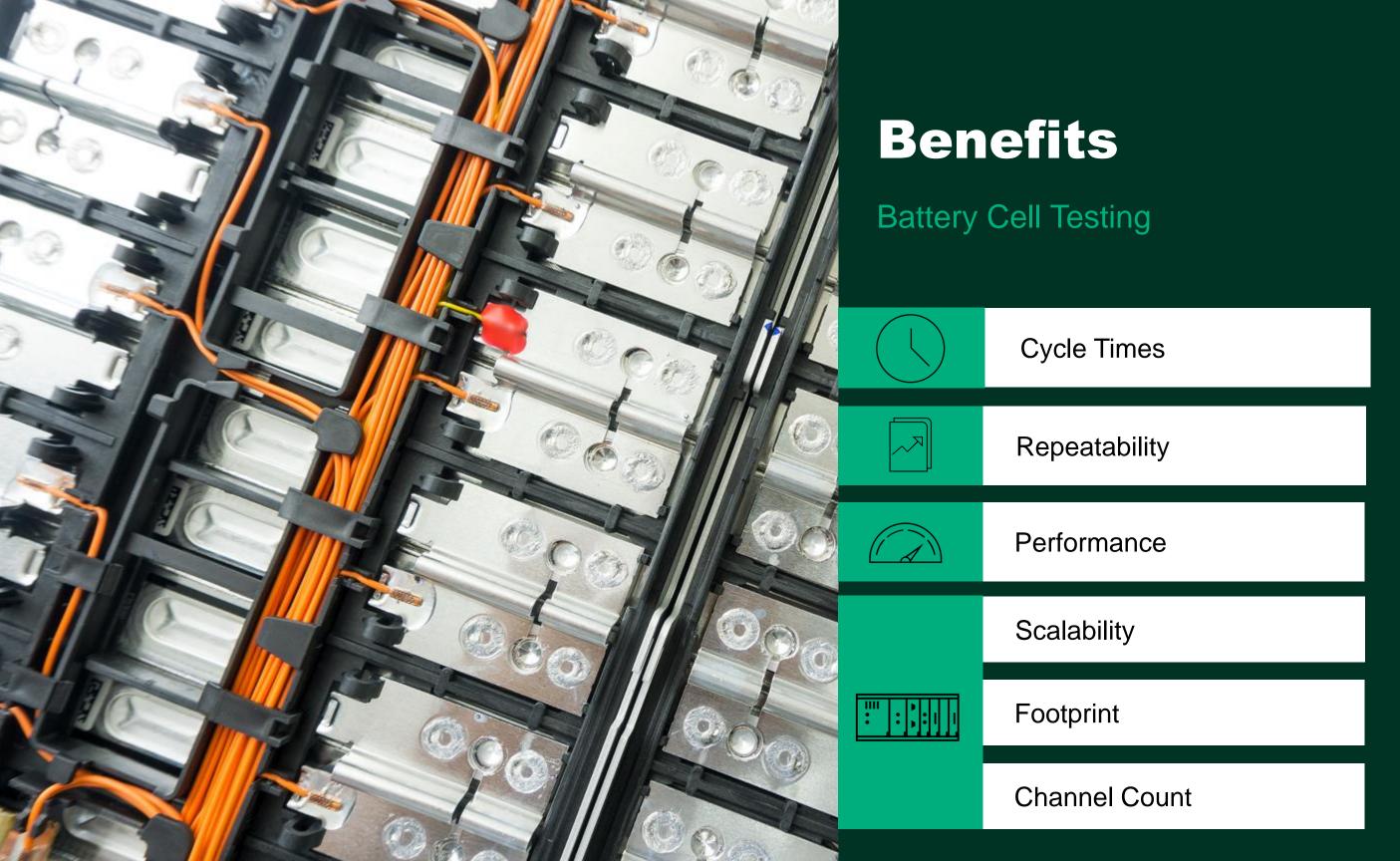
Industry-leader in repeatable and accurate measurements with a wide portfolio enables the right mix of cost and performance

Timing and Synchronization PXI Chassis

PCI Express Gen 3 throughput up to 24 GB/s, sub nanosecond latency, P2P streaming, integrated triggering





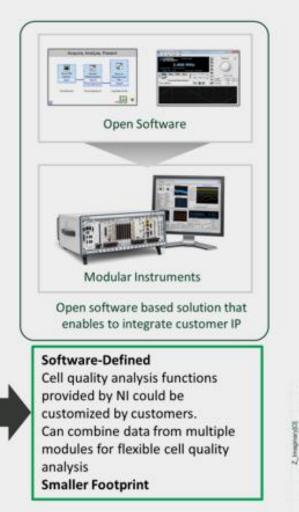


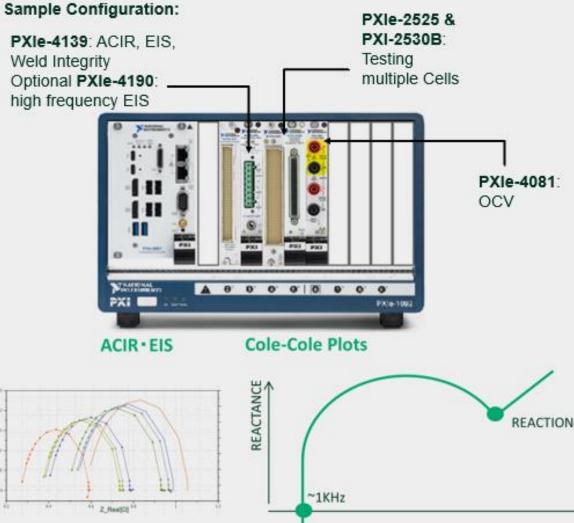


PXI Based Cell Quality Analysis Provides Scalability and Flexibility



methods without access to intermediate data →difficult to understand battery attributes that require customized analysis



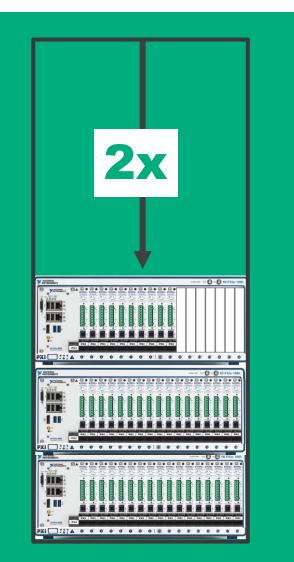






What Does 44 SMU Channels Look Like?





NI 1-ch SMUs

Comparable Power & Specs (Up to 200V, 3A, 40W)

2x Space Savings

Faster Execution

Box SMUs



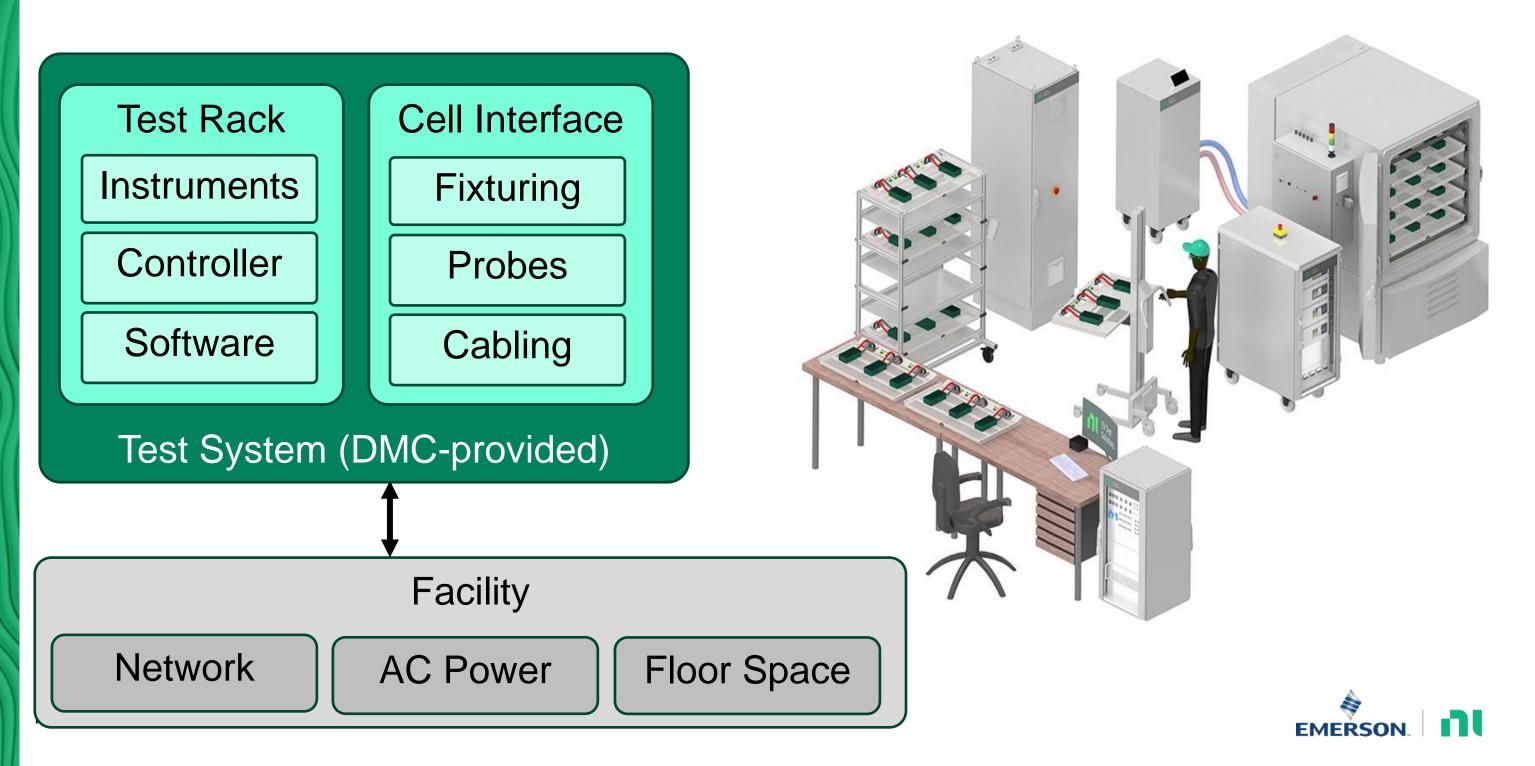


Integration

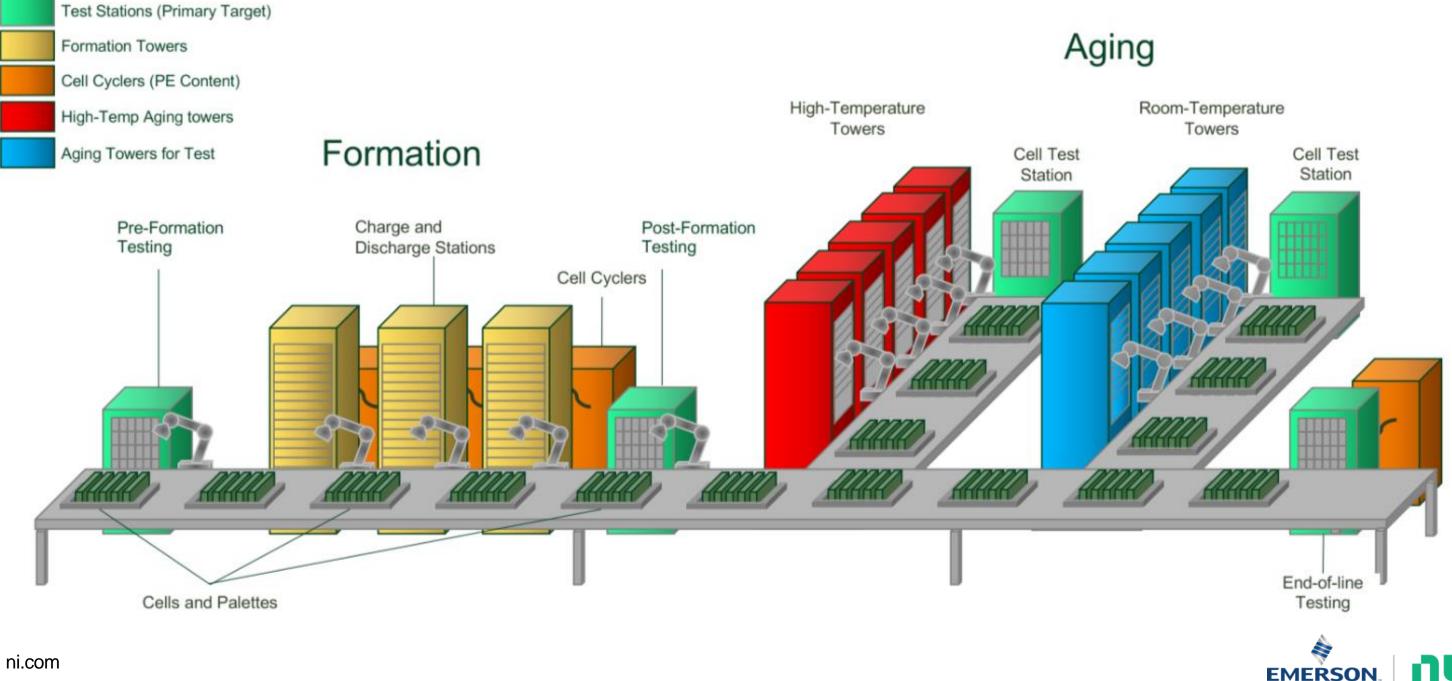




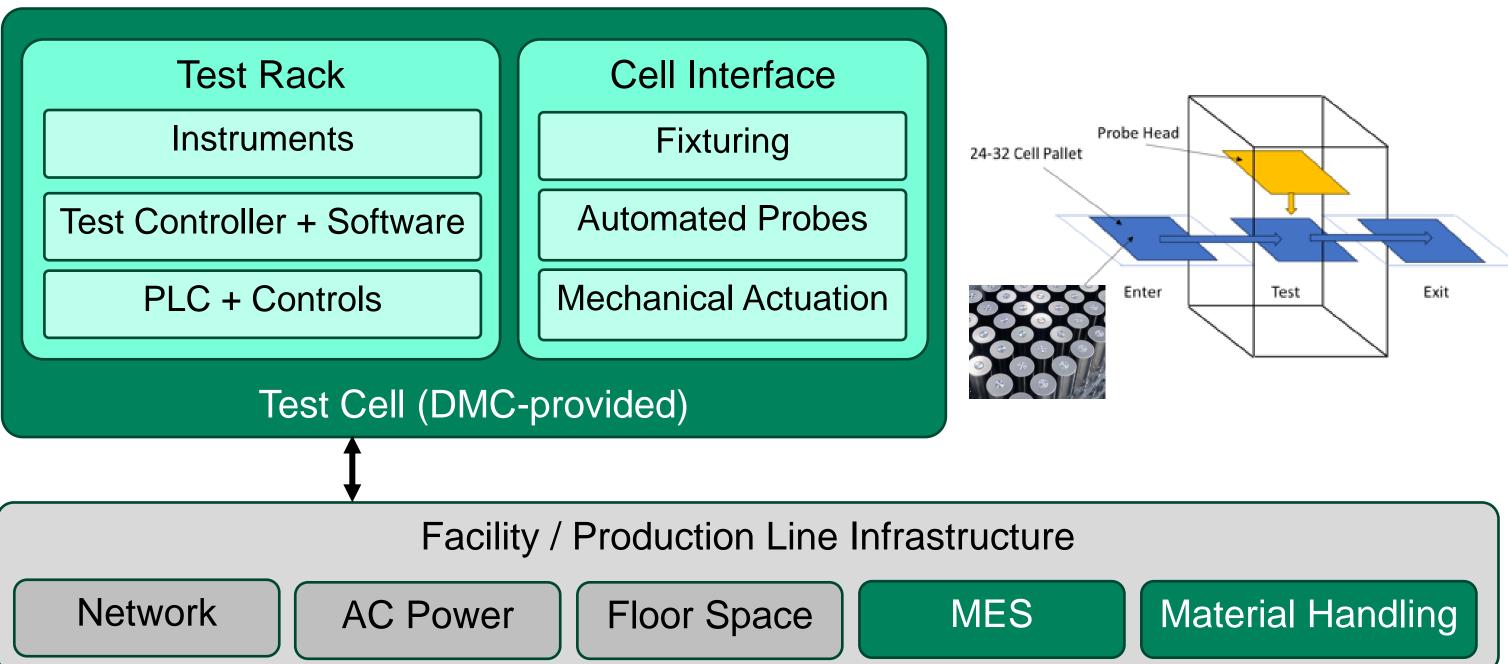
ILOW Volume Production/Validation



Medium/High Volume Production N



Medium/High Volume Production



DMC Service Areas Overview



FEST & MEASUREMENT AUTOMATION

DMC develops software and turnkey systems for automated testing across R&D, validation, production, and field environments using LabVIEW and Python programming and off-the-shelf and custom hardware.

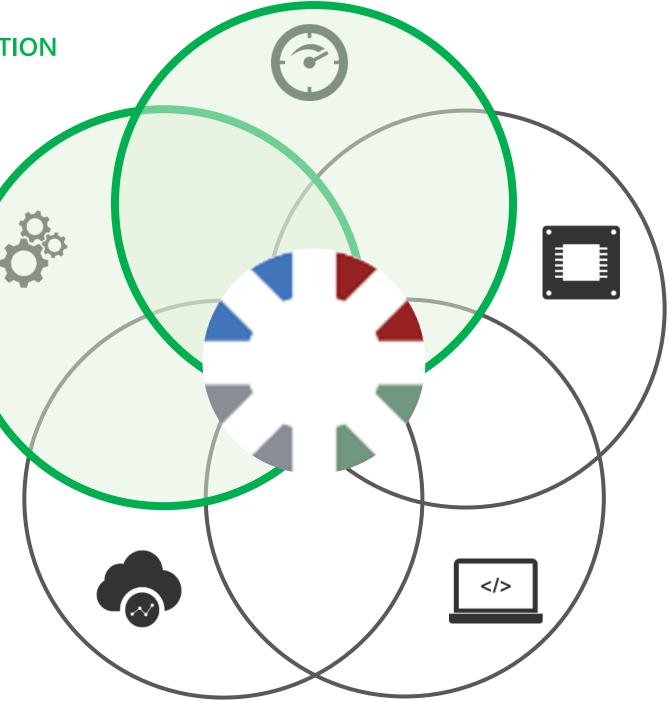


MANUFACTURING AUTOMATION & INTELLIGENCE

DMC programs the systems that keep factory floors running, including PLC, HMI, SCADA, Servos, Robotics and more.



DIGITAL WORKPLACE SOLUTIONS DMC offers hands-on expertise to organizations that want to take advantage of technologies that improve productivity, communication, and collaboration in their digital workplace.



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EMBEDDED DEVELOPMENT & EMBEDDED PROGRAMMING

DMC can help you with your product development needs. Our services include developing intelligent hardware systems from circuit design and custom PC boards to complex embedded systems.



APPLICATION DEVELOPMENT

DMC develops applications that connect to your systems applying intelligent algorithms and structured code including PC apps, web apps, mobile apps, and database driven systems.

DMC Overview

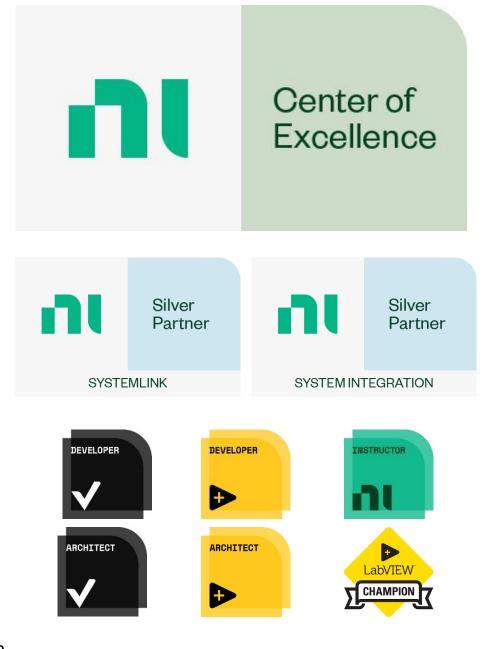
Established in 1996, DMC serves customers worldwide from offices in Chicago, Austin, Boston, Cincinnati, Dallas, Denver, Detroit, Houston, Nashville, New York, Raleigh, San Diego, Seattle, St. Louis, and Washington, D.C.







DMC Certifications and Services



- Battery test consulting
- ATE design/development
- Manufacturing integration



ting opment gration



Device Under Test	R&D / Validation (Functional, HIL,	Production (EOL)	Ren M
	Lifecycle)		
Battery Packs	NI BTS Solution	DMC BPT Solution	<u>DM</u>
Battery Modules	NI BTS Solution	DMC BPT Solution	<u>DM</u>
Battery Cells	DMC Validation Test Platform + NI Cell	<u>DMC Validation</u> <u>Test Platform + NI</u>	<u>DMC</u> <u>Pla</u>
	Quality IP	Cell Quality IP	
Battery Management	DMC BMS Test	DMC BMS Test	D
Systems	Platform	<u>Platform</u>	
ni.com (BMS)			

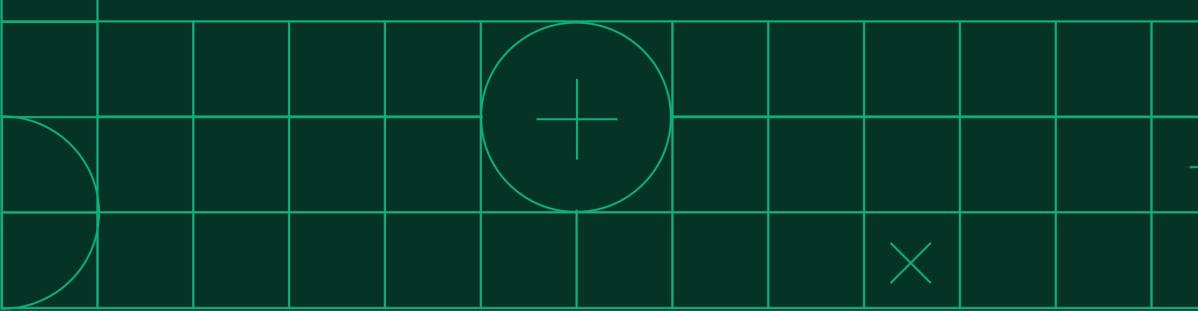
Warranty / manufacturing / Maintenance / Diagnostics

<u>IC BPT Solution</u>

IC BPT Solution

<u>C Validation Test</u> atform + NI Cell Quality IP

<u>DMC BMS Test</u> <u>Platform</u>





• Partner network that can help with the implementation of the solutions. DMC is one of our partners that has been involved in the battery space for over a decade, We have done a lot of work with DMC in the battery cell ,module and pack.



No-Defect Type	Specific Defect	OCV	ACIR	EIS (<1kHz)	EIS (>1kHz)	HPCD (pouch only)	Leakage T
Internal shorts	Torn tab	Maybe	Maybe	Maybe	Yes		Maybe
	Torn separator	Maybe	Maybe	Maybe	Yes		Maybe
	Folded separator	No	Maybe	Maybe	Yes		Maybe
	Dendrites	Maybe	Maybe	Maybe	Yes		Maybe
	Internal shorting	Yes	Maybe	Maybe	Yes		Maybe
	Internal contamination	No	Maybe	Maybe	Yes		Maybe
Welds	Bad tab weld	Maybe	Maybe	Maybe	Yes		No
	Bad fuse weld	Maybe	Maybe	Maybe	Yes		No
After Electrolyte is added	Over/under-lithiation	No	Maybe	Yes	Yes		No
	Graphite slurry defect	No	Maybe	Yes	Yes		No
	Electrolyte additive mixture defect	No	Maybe	Yes	Yes		No
	Improper wetting	No	Maybe	Yes	Yes		No
	SEI composition and distribution	No	Maybe	Yes	Yes		No
Afte	Cell formation recipe assessment	No	Maybe	Yes	Yes		No

_	
est	

Weld Test

No
No
Yes
Yes
Yes No
No
No No
No No No

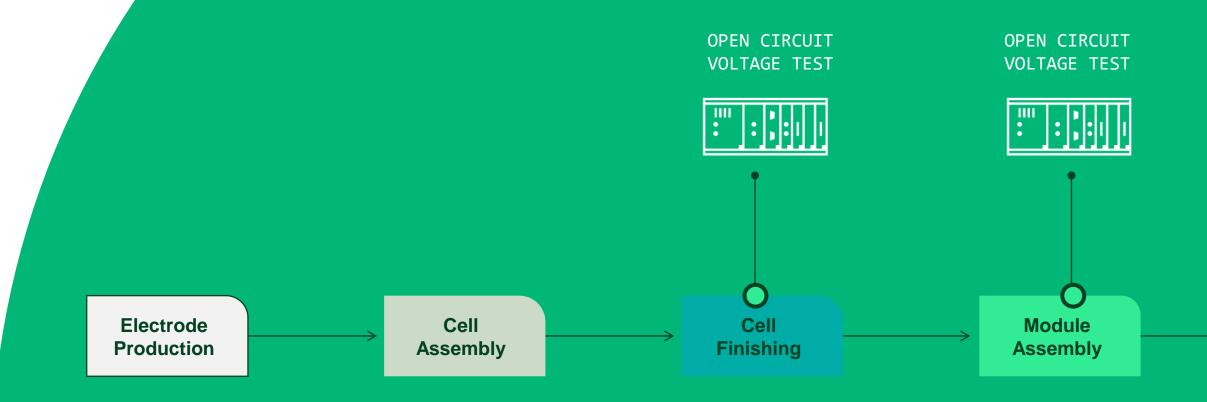




BACKUP and REFERENCE SLIDES FROM THIS POINT ONWARDS



Open Circuit Voltage (OCV)



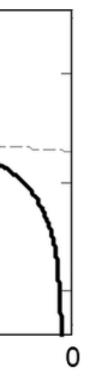
EV BATTERY PRODUCTION PROCESS

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⁴b Voltage [V] 3.5 Zone 3 Zone 2 3 Zone 1 0.4 0.3 0.7 0.9 0.8 0.6 0.5 0.2 0.1 1 SOC

N

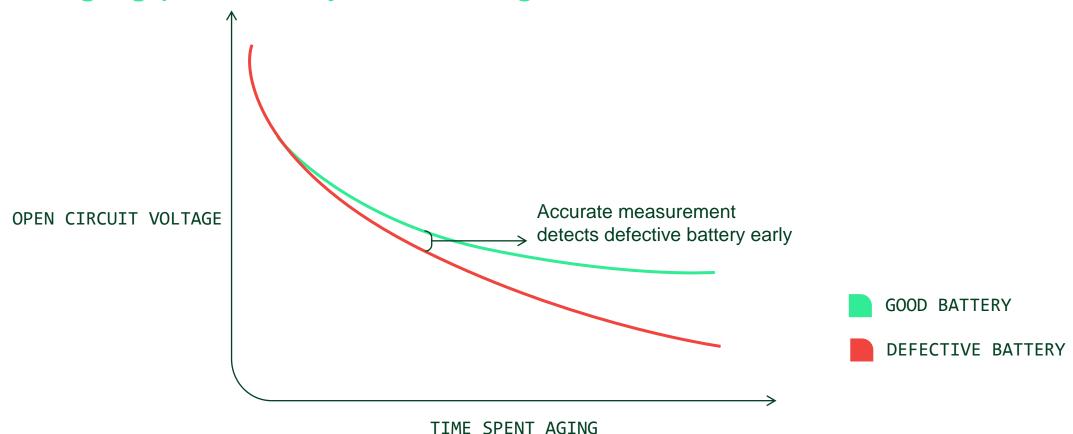


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OPEN CIRCUIT VOLTAGE (OCV)

Test Challenge

Detect micro-shorts that occur during cell aging process by monitoring OCV variation



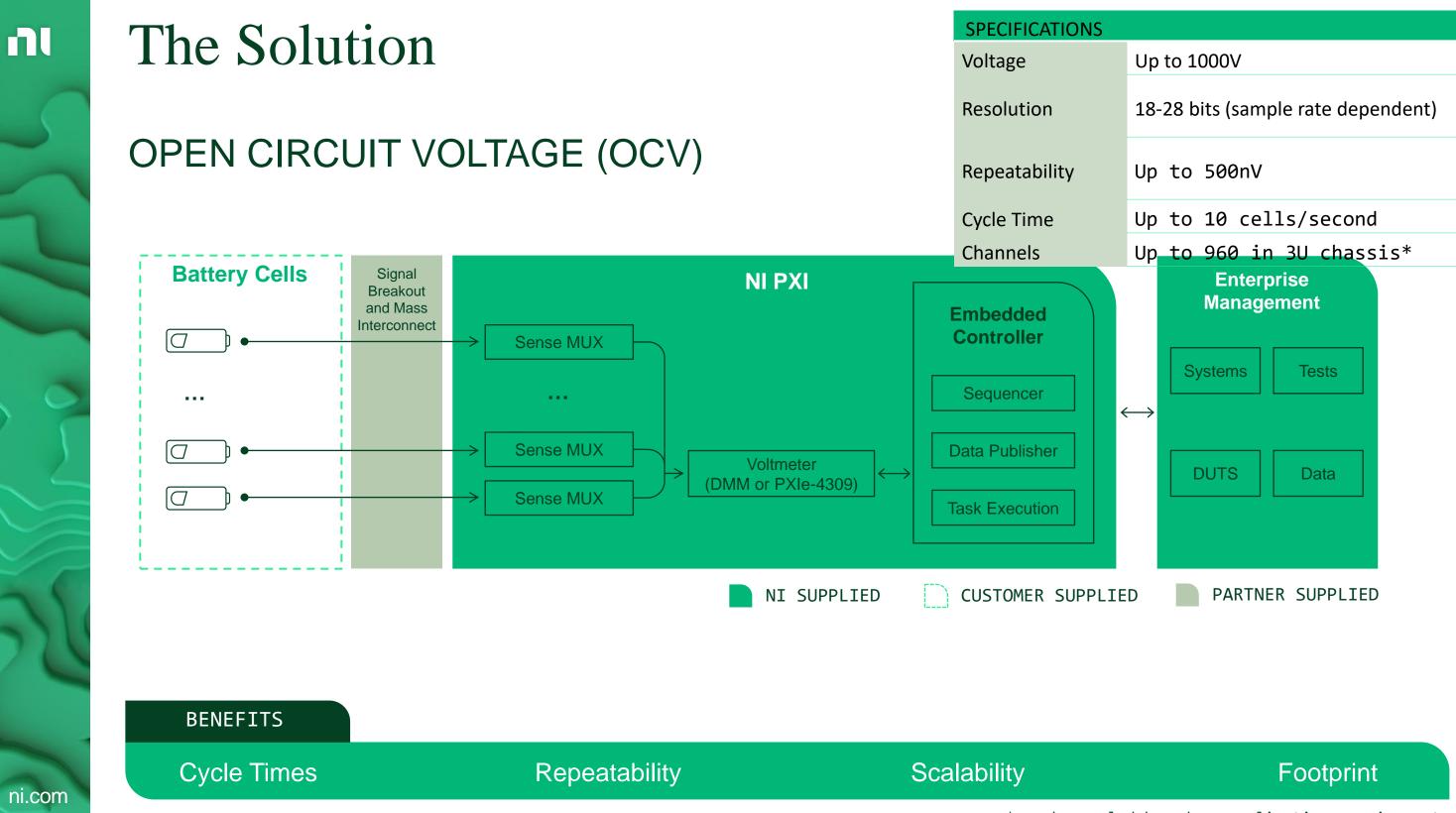
Defective battery OCV changes gradually with time, accurate measurements are essential to early fault detection

REQUIREMENTS

Low Voltage

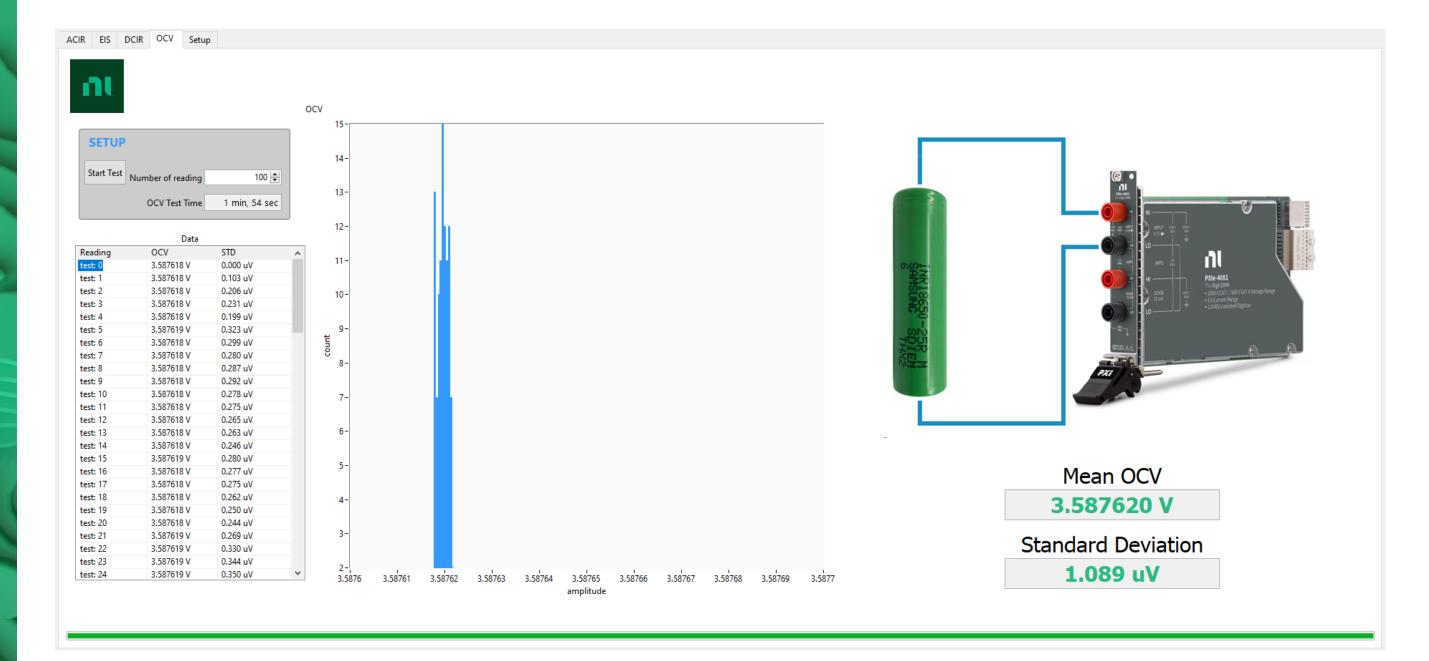
High Repeatability

Fast Cycle Times



*can be scaled based on application requirements

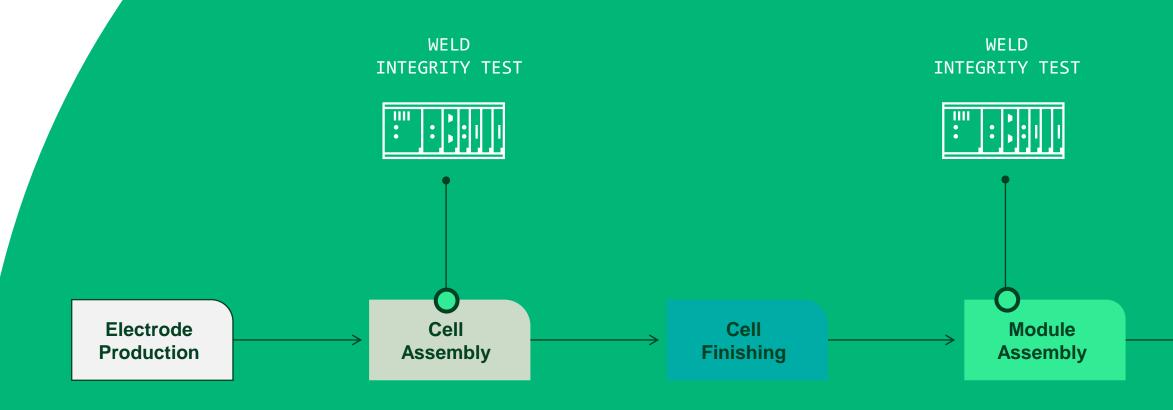
Screen grab of OCV Demo



N



Laser Weld Integrity Test



EV BATTERY PRODUCTION PROCESS

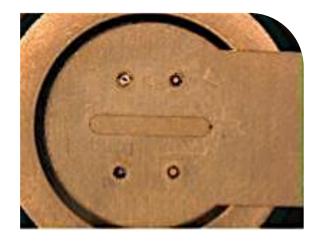
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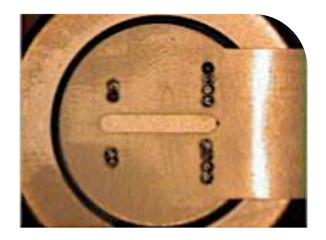


LASER WELD INTEGRITY

Test Challenge

Confirm weld seam quality by measuring resistance





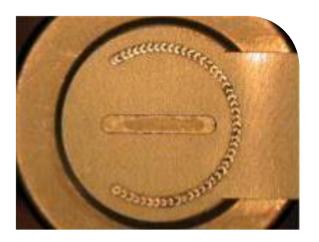


IMAGE SOURCE: <u>Manufacturing Tomorrow: New Laser Sources Improve Battery Performance by Enabling dissimilar Metal Joining</u>

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REQUIREMENTS

$\mu\Omega$ Resistance

nΩ Repeatability

High Speed

Precise Control

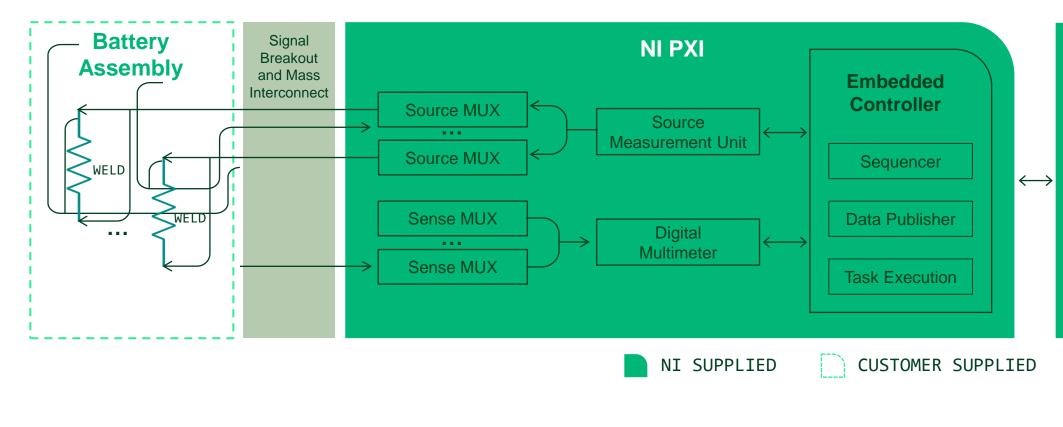


The Solution

LASER WELD INTEGRITY

SPECIFICATIONS

Current Range Cycle Time Channels Isolation



BENEFITS

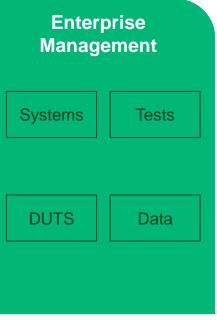
Cycle Times

Repeatability

Scalability

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100mA - 2A				
1μΩ - 10μΩ				
20 - 100 welds/second				
Up to 350 in 3U chassis*				
150V				



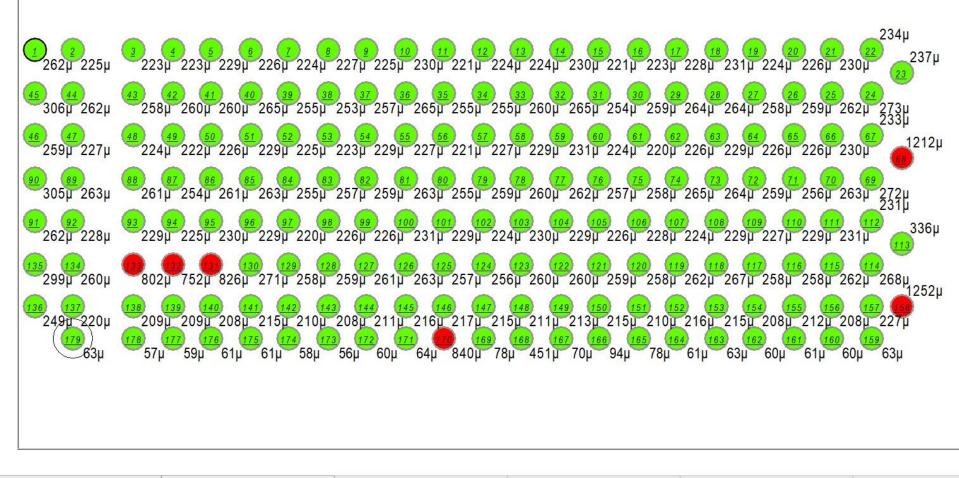
PARTNER SUPPLIED

Footprint

*can be scaled based on application requirements

Screen grab of Laser Weld Integretiy Demo

Batterieinspektor



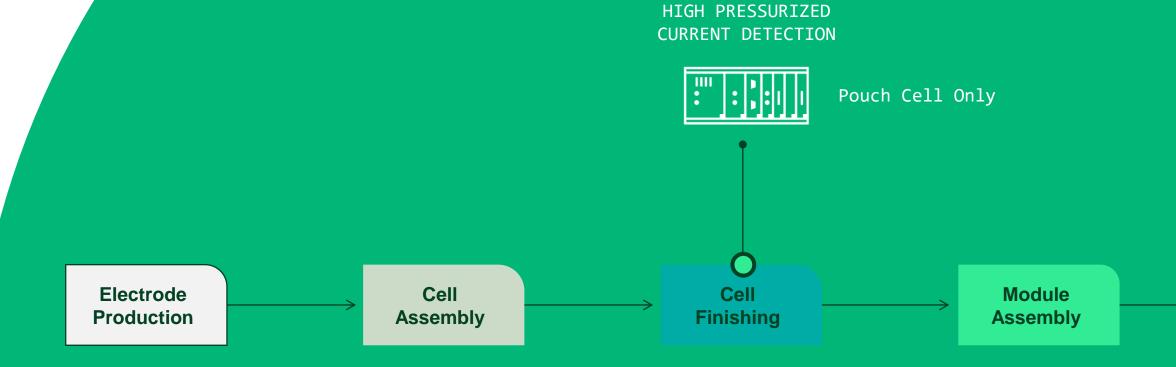
Prüfung	Konfiguration		
SPS_RUN	Bereit		







High Pressurized Current Detection (HPCD)



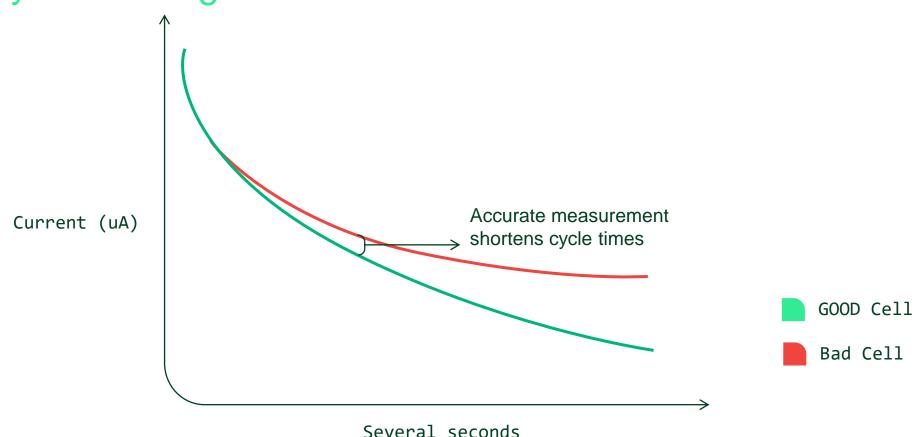
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High Pressurized Current Detection (HPCD)

Test Challenge

Detect bad cells after applying high pressure by monitoring current variation in a short time



Defective battery current changes in few seconds, accurate measurements are essential to shorten cycle times

REQUIREMENTS

Current Accuracy

High Repeatability

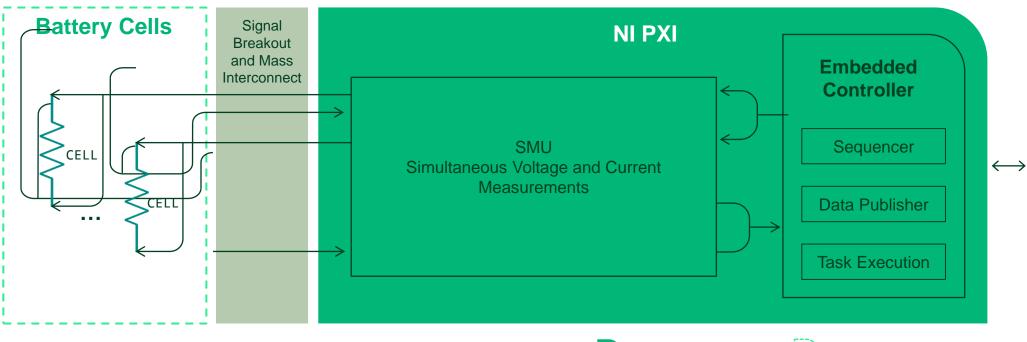
Fast Cycle Times – few minutes to few seconds



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The Solution

High Pressurized Current Detection (HPCD)



Procedure:

NI SUPPLIED

CUSTOMER SUPPLIED

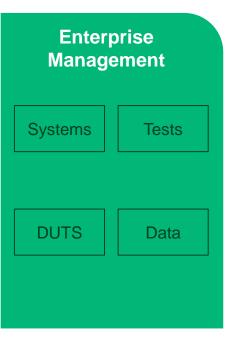
Scalability

- Measure OCV in Constant Current Mode
- Change Pin State to Constant Voltage Mode by setting the voltage to OCV + few uV
- Measure and Monitor Current on a cell for few seconds
- Judge Pass and Fail

BENEFITS

Cycle Times

Repeatability



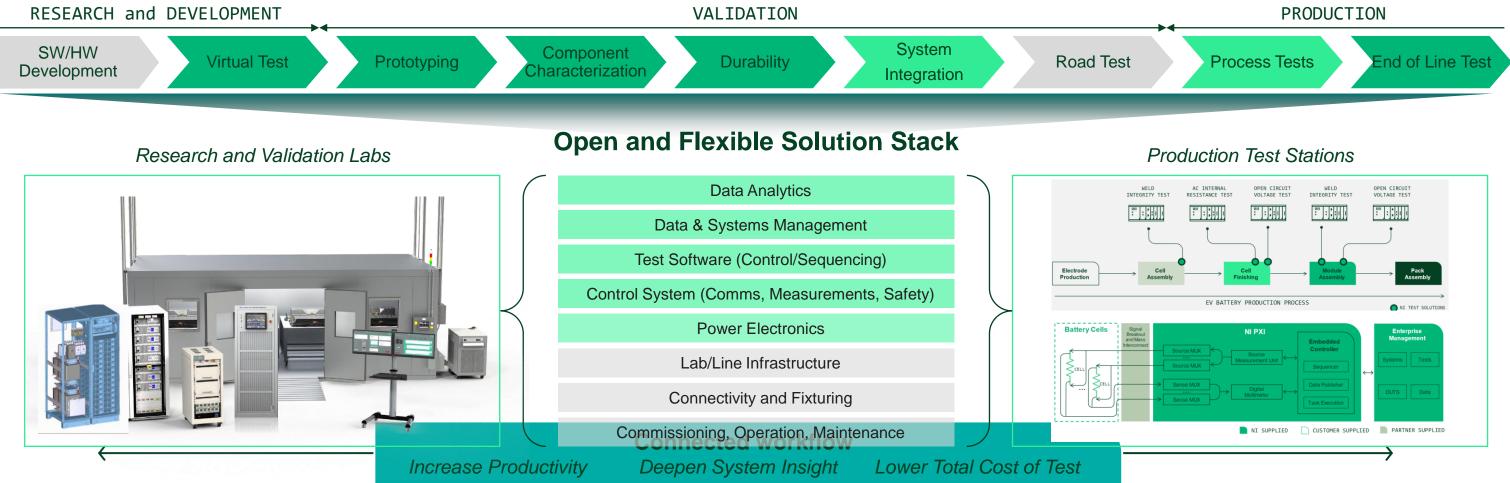
PARTNER SUPPLIED

Footprint

Vision for Serving the Battery Test Workflow

N

We combine best-in-class measurement hardware, power electronics, software, and advanced data modelling techniques to deliver disruptive test solutions that significantly reduce the cost of test and enable auto manufacturers to accelerate their transition to electric vehicles.



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NI Cell Quality | PXI Bundles

Pre-Configured Systems

MEASUREMENT CAPABILITES	Part Number: 866575-10B	Part Number: 866575-11B	Part Nı	
Open Circuit Voltage (OCV)	PXIe-4081 DMM (1000V, 7 ½ DIGIT)			
AC Internal Resistance (AC-IR)				
Electrochemical Impedance Spectroscopy (EIS) – Low Frequency	PXIe-4139 SMU (60V, 1A)			
Electrochemical Impedance Spectroscopy (EIS) – High Frequency	N/A	N/A	PXIe	
Switching and Multiplexing	N/A	PXIe-2525 MUX (2 WIRE 64 CH SW MATRIX (2 WIRE 4X16 S		
Temperature Measurement	PXIe-4353 (32 CHANNEL, THERMOCOUPLE INPUT MC			

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* Power cables needed for the systems are not included within the configurations and need to be another line item on the quote.

NI CUSTOMER CONFIDENTIAL

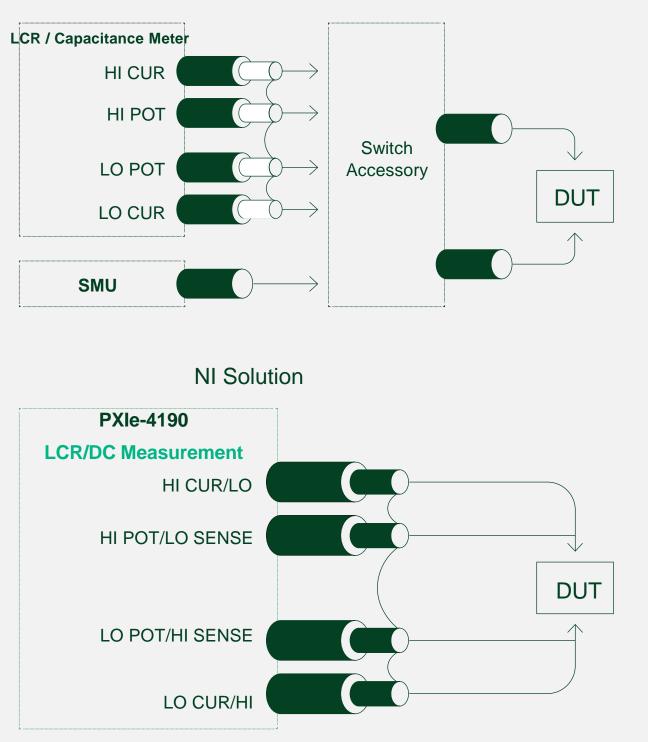
IODULE)

NITCH), PXIe-2530B SWITCH)

e-4190 (2MHz, 40V)

lumber: 866575-18B

Traditional Solution



CELL QUALITY OFFERING OVERVIEW

A Better Solution for Battery Test

NI SMUs combine the functionality of **impedance** and DC instrumentation types into a single form factor- the first instrument of its class.

Power simpler measurement systems with high channel density and no connection changes





- EIS Frequency: .1Hz 1kHz
- Max current source: 3A

PXIe-4190 for High Frequency EIS



- EIS Frequency: 40 Hz 2 MHz •
- Max current source: 70mA

NI CONFIDENTIAL

NI OCV Solution is 3.5x More Accurate than Hioki 4560

The greater accuracy of the NI solution enables a higher-fidelity assessment of leakage current in a form factor that combines OCV and ACIR.

OCV Specifications

NI PXIe-4081: +/-55.4uV of uncertainty (assumes +/- 5C temperature range) Hioki 4560: +/-197uV (.0035%, +/- 5%)

HIOKI RECORD BATTERY MANDAACE METER 21 1000 2160 11000 6.0000 -0 5000 25.6 7

Key Points

- The 4081 has a self-calibration procedure that monitors the temperature drift of the onboard ADCs
- The NI uncertainty assumes a 2-year calibration window
- The Hioki uncertainty assumes a 1-year calibration window
- Hioki does not support a full calibration procedure
- NI uncertainty improves in a tighter temperature range
- Hioki requires an external temperature sensor to achieve specified accuracy, whereas the NI solution is internal
- Hioki has higher-accuracy OCV solution, but this will require a separate box in order to have both OCV and ACIR



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Detailed Differentiators

- 1. Our instrumentation supports a broader range of frequencies for EIS, which enables analysis at different parts of the spectrum correlated with specific failure modes (specific spectrum is cell specific). Note that the addition of the 4190 enables ~2MHz, which is useful for specific defects
- Our SMUs enable customization of the current range, which can be used to ensure the appropriate current is sourced to accommodate custom switch routing and production fixturing
- 3. The PXI form-factor enables a high density of measurements in a single chassis (ACIR, OCV, HPCD, Leakage, EIS, and more..)
- 4. The PXI form-factor also enables a mix of simultaneous and multiplexed inputs, which lets the customer balance cost and performance for their ideal throughout. For example, combine a bunch of 4147s for high density of simultaneous channels, or combine them with 2525s for even higher density at a lower price point per channel
- Our software provides an API that enables extensive customization at the API, data and presentation layers 5.
- Our calibration procedure enables very precise measurements to be performed with custom fixturing and 6. signal routing
- Our time per measurement is generally faster thanks to the high-performance nature of PXI (of course, depends on specific measurement and setup, but referring mainly to ACIR)
- Our accuracy and resolution are best-in-class. This is hard to benchmark because every EIS/ACIR 8. measurement changes the SoC of the cell slightly, but initial testing has shown a smaller standard deviation than a Hioki box
- 9. Our solution is better suited for large cells with capacity over 140Ah (some of the competitors will struggle with larger sizes – we need to better quantify and assess this)

Batteries are a Limiting Factor

Expensive and time-consuming to produce

Significant variability in manufacturing process

Defects are difficult to detect

Directly impacts vehicle performance and safety

Significant impact on overall margin and profitability

Undergoing constant changes and improvements

Sensitive to supply-chain challenges

Need for strict control over transportation and handling

Requires significant investment into new equipment and personnel retraining

Field failures can have significant impact on brand and consumer sentiment



Battery Production Challenges

Cell Production



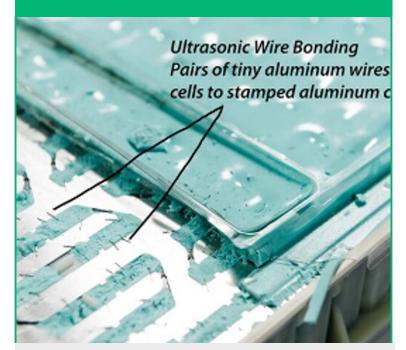
New cells are charged precisely to coat the electrolyte before a lengthy aging and testing process

Challenge:

Achieving massive scale while improving profitability and maximizing quality

Weeks

Module and Pack Assembly



Cells are composed into a subassembly structure and ultimately combined with electronics to produce a final pack

Challenge:

Ensuring the quality and consistency of incoming components and assembly processes to minimize rework

Minutes - Days





Challenge: their longevity

Service and Remanufacturing



Batteries are evaluated to determine if they are still operating correctly and evaluated for second-life applications

Accurately characterizing the quality and utility of modules and cells to maximize

Days

Cell Production



New cells are charged precisely to coat the electrolyte before a lengthy aging and testing process

Challenge:

Achieving massive scale while improving profitability and maximizing quality

Weeks

Overview of Cell Manufacturing Challenges

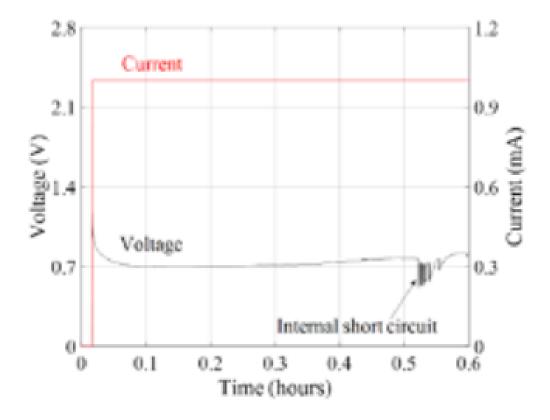
Volume of cell production is one of the largest bottlenecks limiting the market's ability to achieve ambitious EV production targets for a combination of the following reasons:

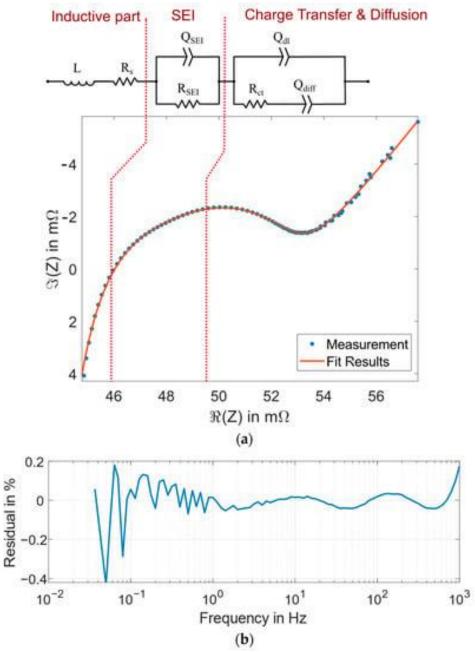
- The time required to produce a new cell is significant (8 12 days), which necessitates achieving a massive operational scale
- Yields of cells are limited due to high variability in the manufacturing processes
- 3. Defects during the manufacturing process can be difficult to detect and they present significant risk to product performance and safety
- Every interaction with cells increases the risk of introducing subtle 4. defects or damage, thereby introducing the need for additional timeconsuming test activities
- Ongoing improvements to cell formulation and form-factor may lead to 5. more regular changes to the production process
- The complexity associated with servicing large and cumbersome power electronics

Achieving massive scale while maximizing profitably will require new approaches to manufacturing and test that increase throughout while also ensuring the products are exhaustively tested and that any defects can be rapidly isolated and corrected

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Measurement to defect correlation





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